EI-27003: Electronics Devices and Circuits Lecture - 15

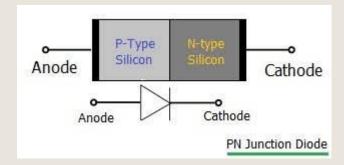
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LECTURE - 15

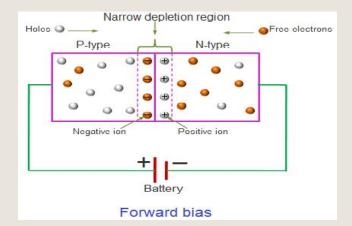
Year: 2020-21

Unit – 2/3: Diode and BJT Modeling

PN Junction Diode



Forward Bias Diode:



Wide depletion region

Reverse bias

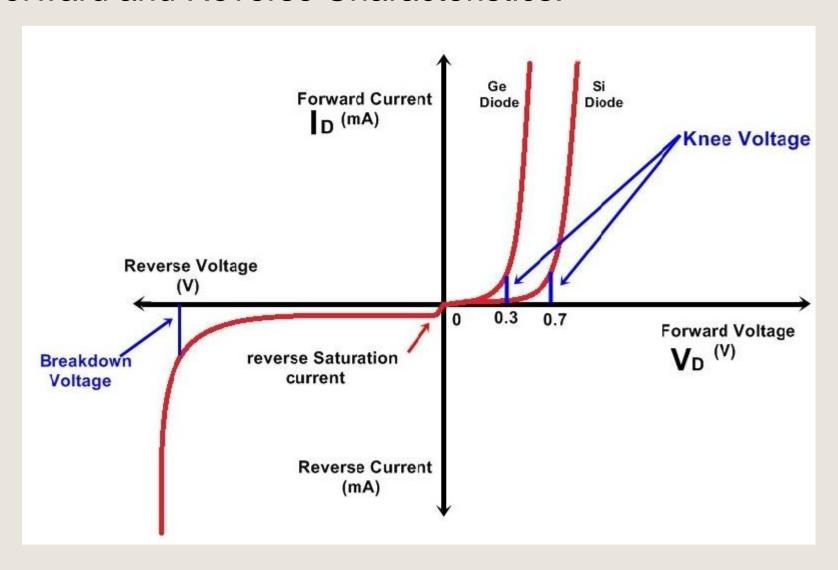
P-type

Free electrons

Reverse Bias Diode:

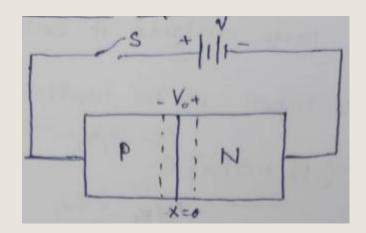
VI Characteristics of PN Junction Diode

Forward and Reverse Characteristics:



Diode Equations

- Here we will obtain the equations:
- Diode current Equation: I_D
- ➤ Built-in Potential V₀
- Width of Depletion layer W



- Let us consider an open circuit PN junction
- \triangleright Let hole and electron densities in p-region be P_p and n_p respectively.
- Let hole and electron densities in N-region be P_n and n_n respectively.

The density of holes in p-region and density of holes in n-region are related by Boltzman relation as:

$$P_p = P_n e^{V_B/V_T}$$

Where V_B is barrier potential across depletion layer and V_T is 'Volt-equivalent of Temp'.

•
$$V_T = \frac{KT}{q}$$

For open circuited PN junction: V_B = V₀

• Hence
$$P_p = P_n e^{V_0/V_T}$$
 ----(1)

- Now consider PN junction is biased in forward direction by applying a voltage V by closing switch S
- Now the barrier potential decreases from its equilibrium value V₀ by V

• i.e.
$$V_B = V_0 - V$$

- With forward bias, hole density in p-region remains constant upto depletion region while in N-region just at junction it increases from p_n to p_n + Δp_n due to diffusion of holes across the junction.
- As the holes diffuse further in N-region, they combined with electron and their density decreases with increase of distance from the junction.
- Ultimately at large distance it becomes the same as p_n
- Now the hole density in N-region can be written as

•
$$P_p = (P_n + \Delta P_n)e^{(V_0 - V)/V_T} = (P_n + \Delta P_n)e^{V_0/V_T}e^{-V/V_T}$$
-----(2)

Substituting the value of P_p from eq.(1) into eq.(2)

•
$$P_n e^{V_0/V_T} = (P_n + \Delta P_n) e^{V_0/V_T} e^{-V/V_T}$$

•
$$P_n = (P_n + \Delta P_n) e^{-V/V_T}$$

•
$$P_n e^{V/V_T} = (P_n + \Delta P_n)$$

• OR

•
$$\Delta P_n = P_n (e^{V/V_T} - 1)$$
 ----(3)

- From eq.(1) $P_n = P_p e^{-V_0/V_T}$ ----(4)
 - Substitute eq(4) in eq(3)

•
$$\Delta P_n = P_p e^{-V_0/V_T} (e^{V/V_T} - 1)$$
 ----(5)

• The diffusion of holes constitutes hole current. This hole current I_p is proportional to ΔP_n

•
$$I_p \not\in \Delta P_n$$
 or $I_p \not\in P_p e^{-V_0/V_T} (e^{V/V_T} - 1)$

•
$$I_p = I_{sp} (e^{V/V_T} - 1)$$

Similarly, electron current due to diffusion of electrons from N-region to P-region is:

•
$$I_n = I_{sn} (e^{V/V_T} - 1)$$

Hence the total current is sum of hole current and electron current

•
$$| = |_p + |_n = |_{sp} (e^{V/V_T} - 1) + |_{sn} (e^{V/V_T} - 1)$$
• OR

- $I = I_0 (e^{V/V_T} 1)$ where $I_0 = (I_{sp} + I_{sn})$ is called reverse saturation current
 - I = I₀(e^V/_{VT} 1) is diode current equation
 More generalize

•
$$I = I_0(e^{V/\eta V_T} - 1)$$

• Where η =1 for Ge and η =2 for Si

Google form - Attendance

https://forms.gle/jkSGtH4U14NB2PAYA